

Towards 20kW CO₂ laser system for Sn-LPP EUV source – review of developments at Gigaphoton

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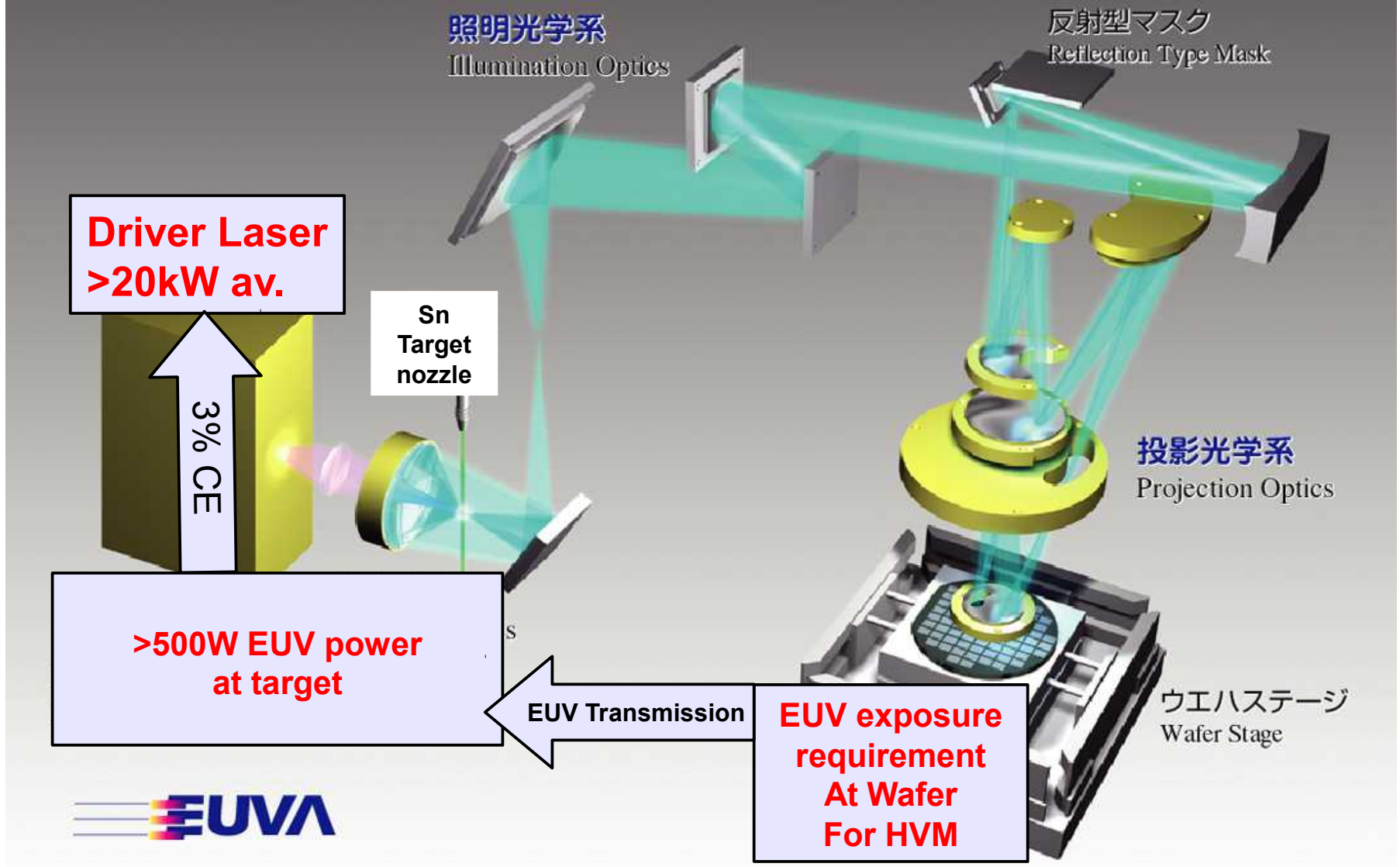
In this talk

- **Introduction**
 - ✓ **Drive laser power requirements**
 - ✓ **Approach to realization of LPP laser driver**
 - ✓ **Challenges**
- **Pursuit of efficient pulsed amplification**
 - ✓ **Development of multi-pass amplifiers**
 - ✓ **Multi-line tunable Master Oscillator**
 - ✓ **Multi-kW multi-line output achieved to date**

Introduction

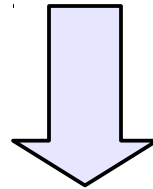
- **Sn-LPP EUV source - Laser Driver power requirements**
- **Viable solution - MOPA-type Laser Driver**
- **Technical challenges on a route to 20kW Laser Driver power**

Laser-Produced-Plasma Sn EUV source – current power requirements for HVM (2010)



Output requirements for a LPP laser driver (2010-onwards)

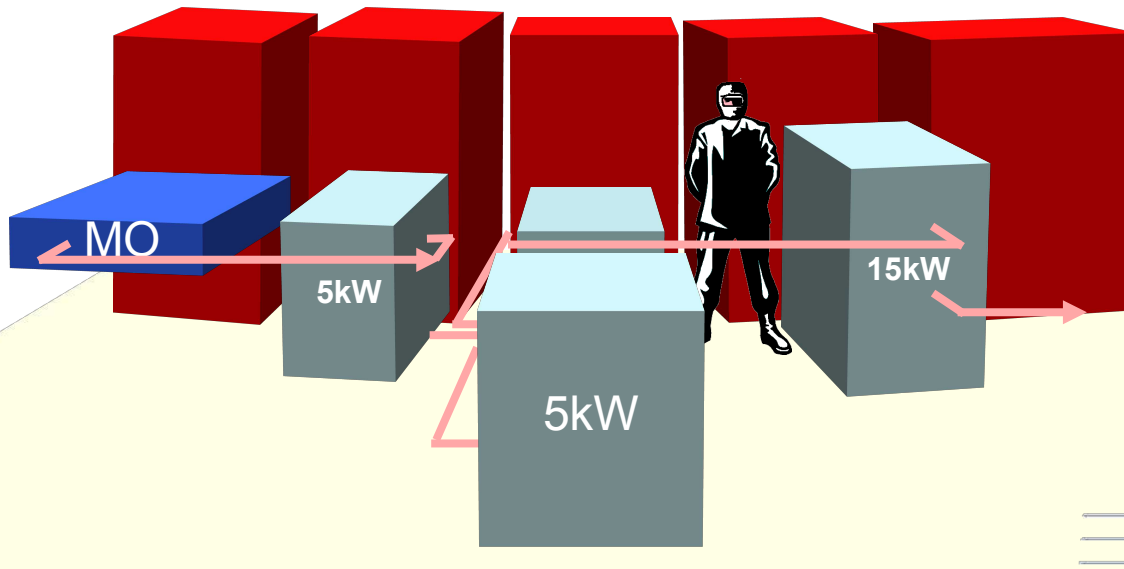
- **High average power output >20kW**
 - ✓ 500W clean EUV at IF
- **Pulse duration 15-50ns**
- **High pulse repetition frequency (hundreds of kHz range)**
- **Pulses On-Demand – must be synchronised with droplet target**



**A viable solution – a pulsed CO₂
Master-Oscillator-Power-Amplifier (MOPA) system
employing Fast-Axial-Flow (FAF) multi-kW amplifiers**

Record output power achieved from a pulsed CO₂ MOPA* system (2008)

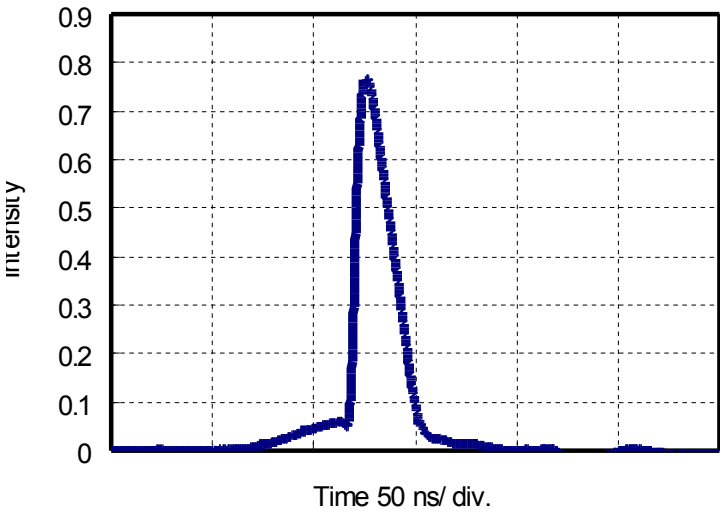
- **12.5kW (1.25kW at 10% duty factor) at 100kHz repetition, 20ns pulse duration**
- **Beam quality $M^2 \sim 1.2$ (at 10% duty).**



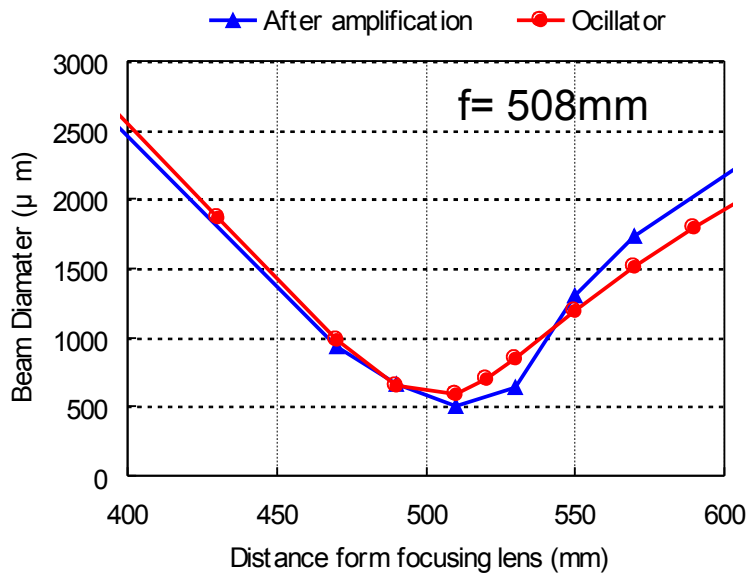
* H. Hoshino, T. Suganuma, T. Asayama, K.M. Nowak, M. Moriya, T. Abe, A. Endo and A. Sumitani,
“LPP EUV light source employing high power CO₂ laser”, SPIE Adv. Lithography 2008, 6921-115, 24 - 29 Feb, San Jose, US

Some performance figures of the MOPA* system (2008)

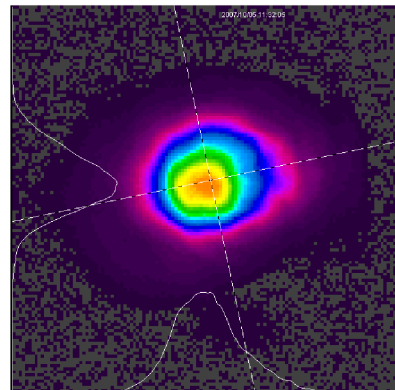
Temporal pulse shape



Beam quality



Laser beam profile



Pulse duration : 20 ns (FWHM)
Pedestal component : <10%

Beam quality: M2=1.2
(10% duty factor).



* H. Hoshino, T. Suganuma, T. Asayama, K.M. Nowak, M. Moriya, T. Abe, A. Endo and A. Sumitani, "LPP EUV light source employing high power CO2 laser", SPIE Adv. Lithography 2008, 6921-115, 24 - 29 Feb, San Jose, US

Some of encountered technical difficulties en route to 20kW power

- **Low amplification efficiency of 15-50ns CO₂ laser pulses in FAF amplifiers**
 - ✓ Max pulsed power extraction down to 35% of CW extraction in single-pass amplifier systems, resulting in many amplifiers needed
 - ✓ Multi-pass arrangements are impractical with FAF amplifiers
 - ✓ High input power requirement for reasonable extraction
- **High system pass-through gain**
 - ✓ Presence of ASE and self-oscillations
- **MO instability due to retro-light**
 - ✓ Reflections from plasma
 - ✓ ASE/self-oscillations
- **Thermal loading of optical components**
 - ✓ Serious at multi-kW levels

This talk addresses the problem of Extraction Efficiency

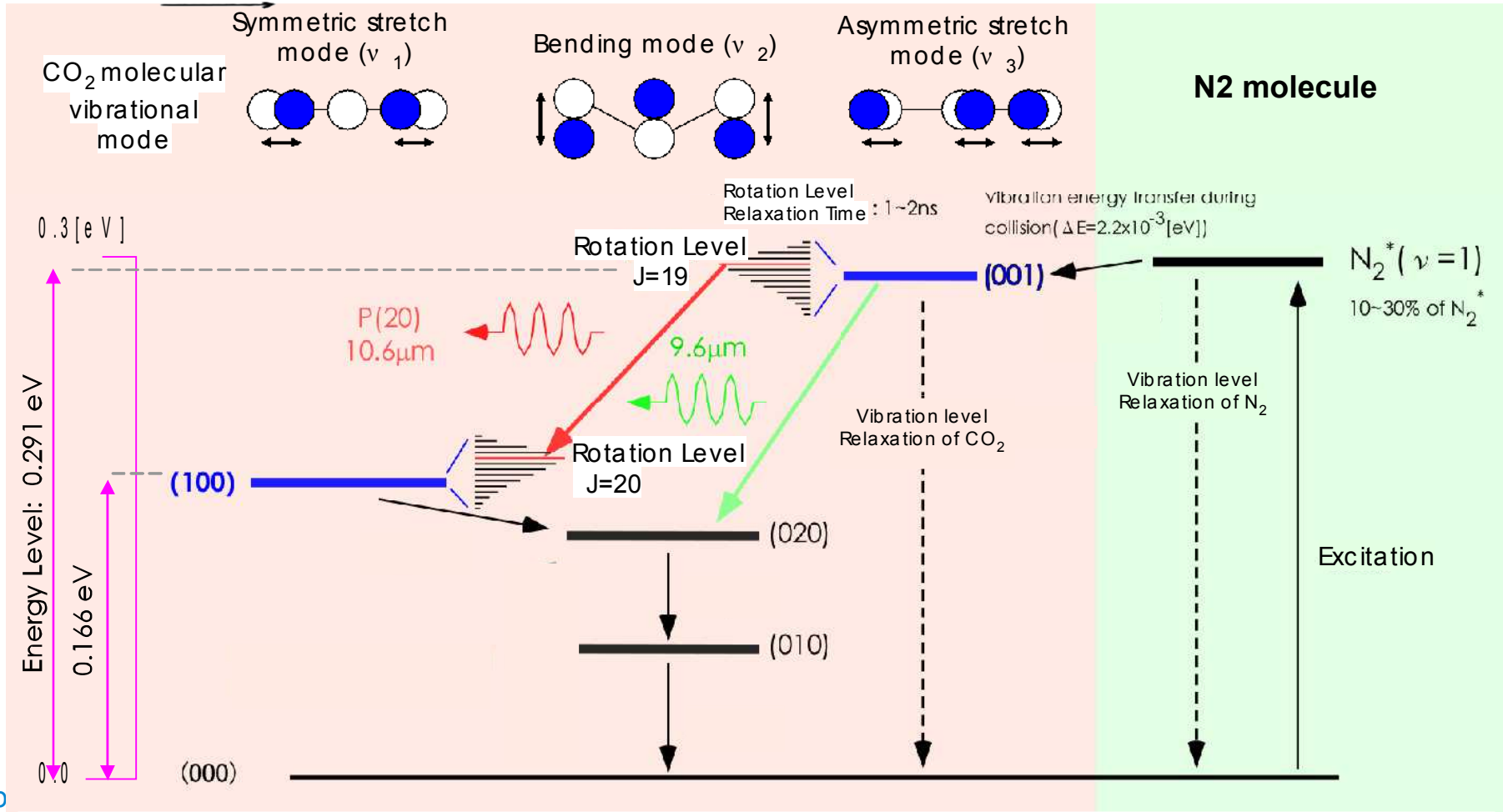
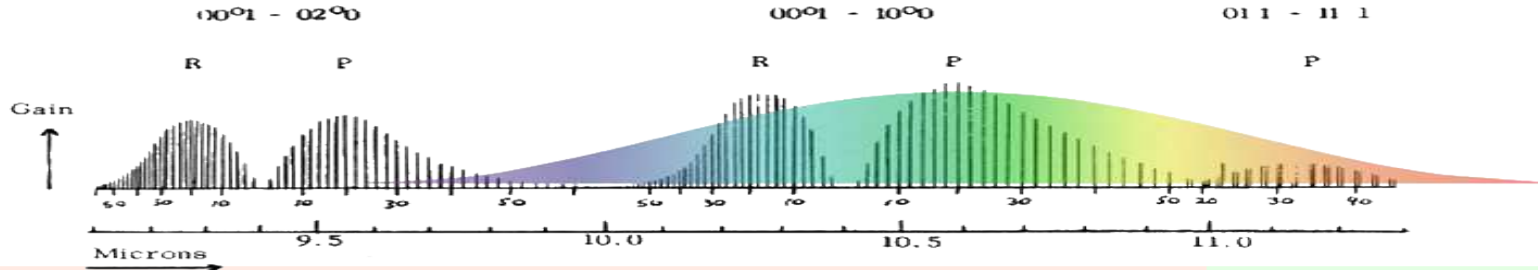
Efficient pulsed amplification of ns CO₂ pulses

- **What “efficient” means and why we need it**
- **Difference between CW and pulsed amplification - where is the “missing” laser power?**
- **Routes to increased amplification efficiency**

What is “efficiency” and why it is welcome

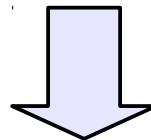
- **“Efficiency” is a short for Power Extraction Efficiency from a laser amplifier**
 - ✓ **It describes the relative performance of the amplifier with pulsed input as compared to a laser output before conversion into an amplifier operated at the same RF duty level**
 - ✓ **It is NOT a wall-plug efficiency of the laser system**
- **High efficiency is key to:**
 - ✓ **Reduction of system cost (footprint and power supply)**
 - ✓ **Reduction of residual gain available to retro-pulses**
 - ✓ **Reduction of average gain level in the period between pulses**
 - Reduction of ASE
 - Reduction of all-system (global) self-oscillations

Why CW and pulsed operation are different?



Routes to CO₂ MOPA efficiency increase

- **Bandwidth-matched input signal**
 - ✓ **Provide input bandwidth matching the bandwidth of laser gain line for maximum interaction cross-section**
 - ✓ **Excite multiple laser transitions of the gain medium simultaneously**
- **Maximize signal-medium interaction time and rate**
 - ✓ **Multi-pass amplifier arrangement**



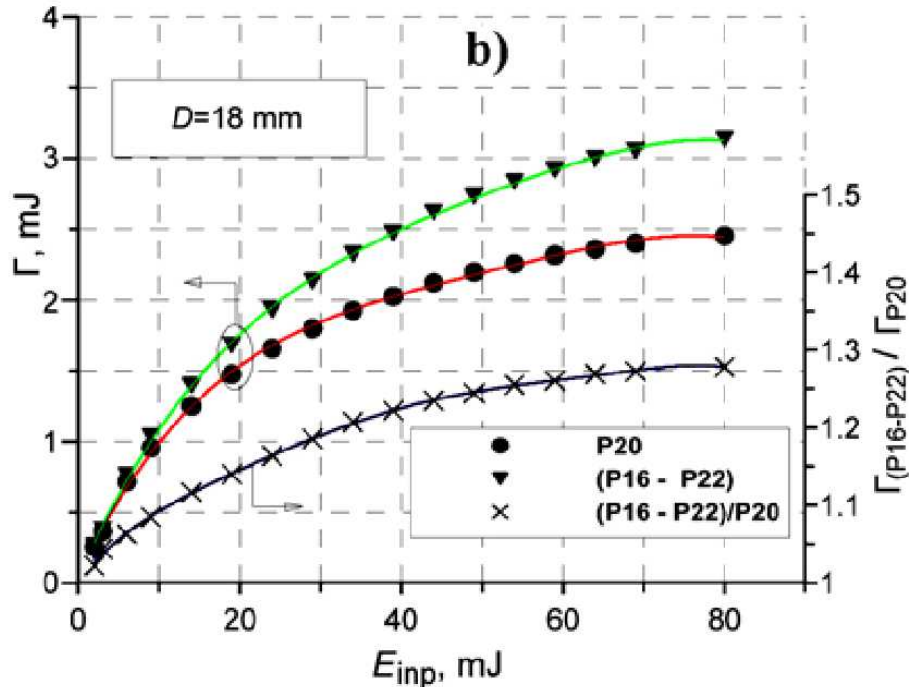
Key aspects:
Master Oscillator
Pre-amplifier arrangement

Multi-line Master Oscillator

- **Predictions of Multi-Line amplification**
- **Novel solid-state seeded CO₂ multi-line oscillator**
 - Custom design for LPP

Multi-line amplification for 20ns pulses – prediction (2005)

Numerical Calculation Result of Amplification with Multi-Line Oscillator



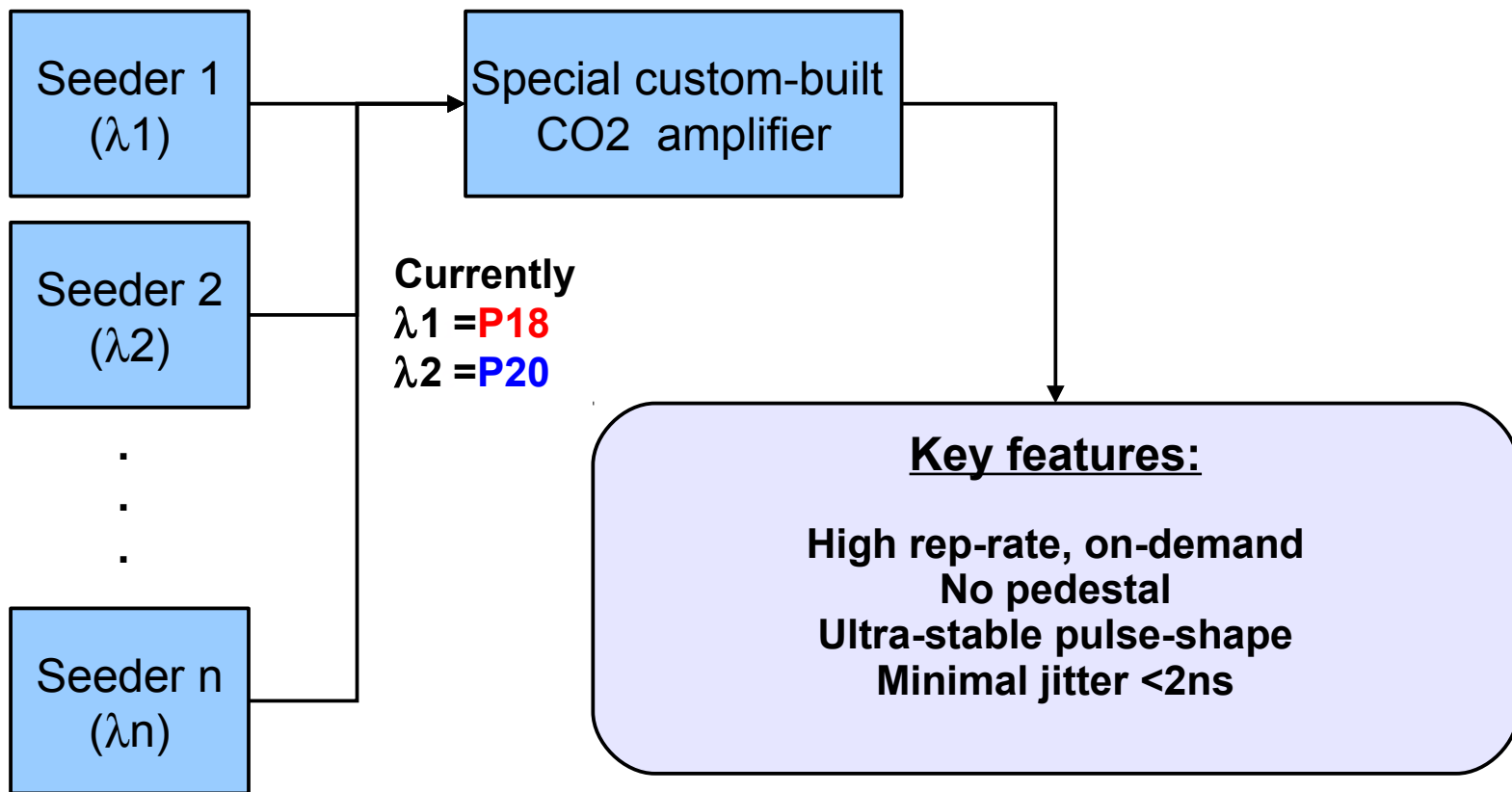
This work was preformed by
Research Institute for Laser Physics,
St. Petersburg, Russia [V.E. Sherstobitov]



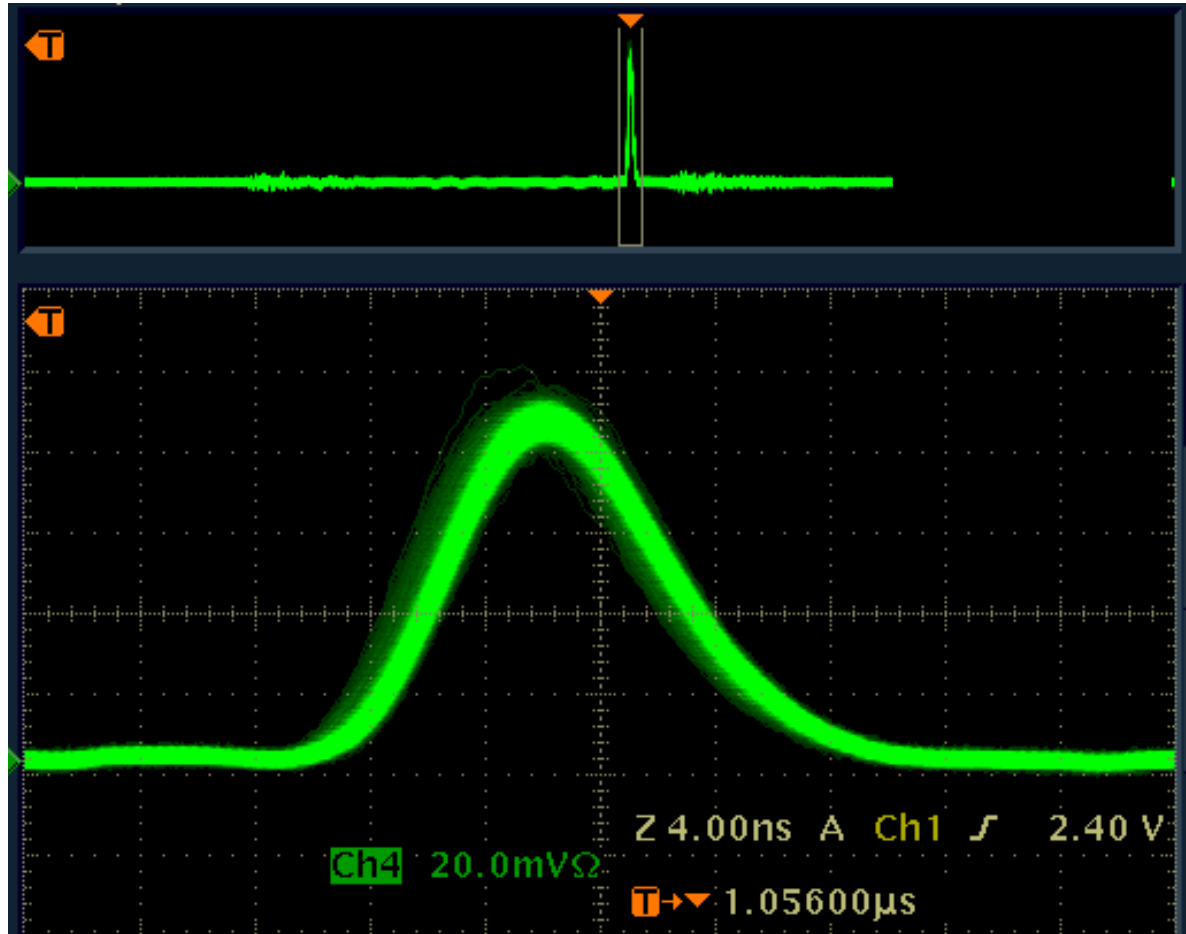
-X- is the amplification ratio
between the (P16-P22) spectrum
and the P20 line

Up to 30% energy extraction improvement predicted with
4 lines P16-P22 of 00^01-10^00 rotational manifold of CO_2

Novel approach to multi-line ns pulse generation at 10.6 microns – amplification of QCL seed (2009)



Performance of multi-line Master Oscillator – Exceptional stability of pulse envelope (early 2010)

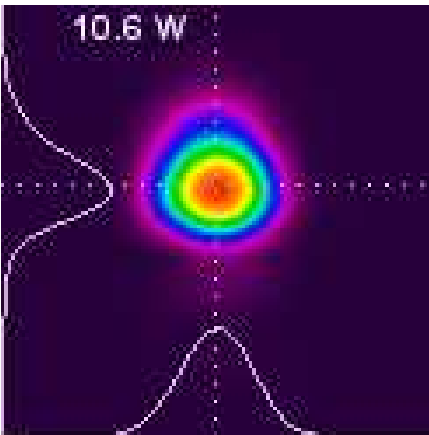


Accumulated traces of 3.5million pulses (35 seconds “exposure”)

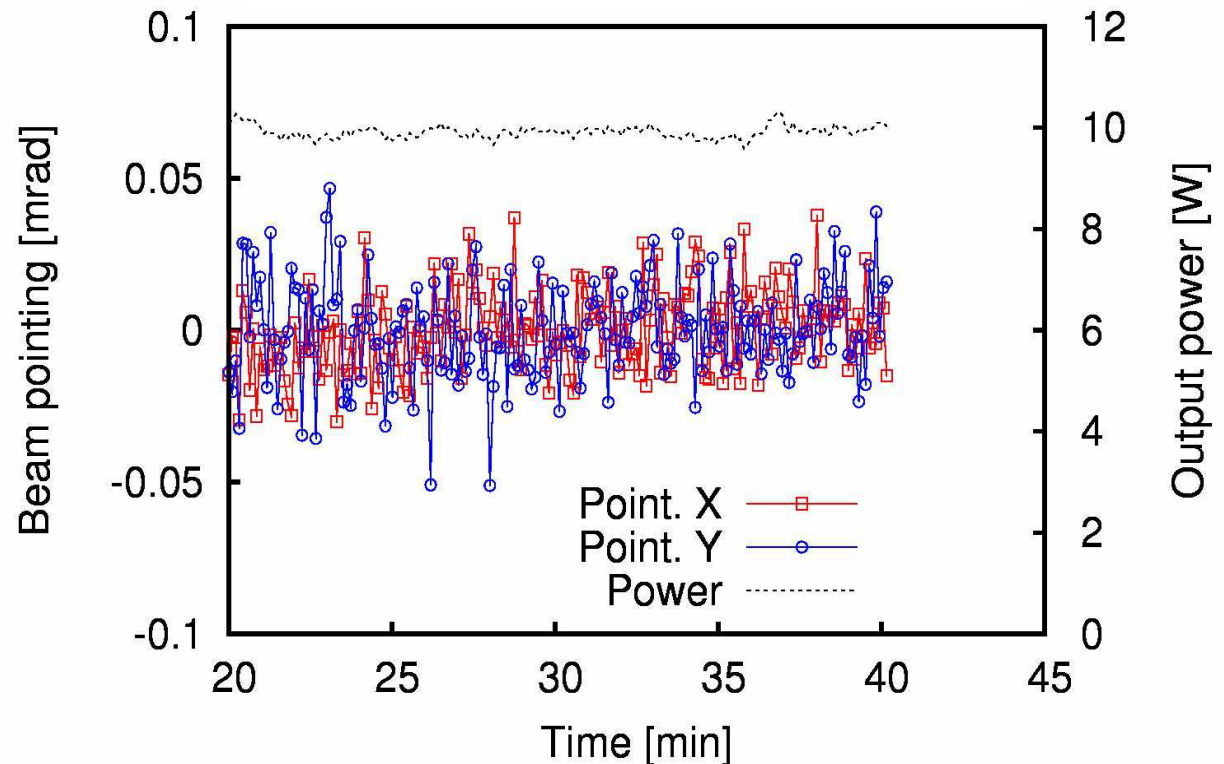
Performance of multi-line Master Oscillator – Stable output beam of high quality (early 2010)

High output
beam quality
 $M < 1.3$

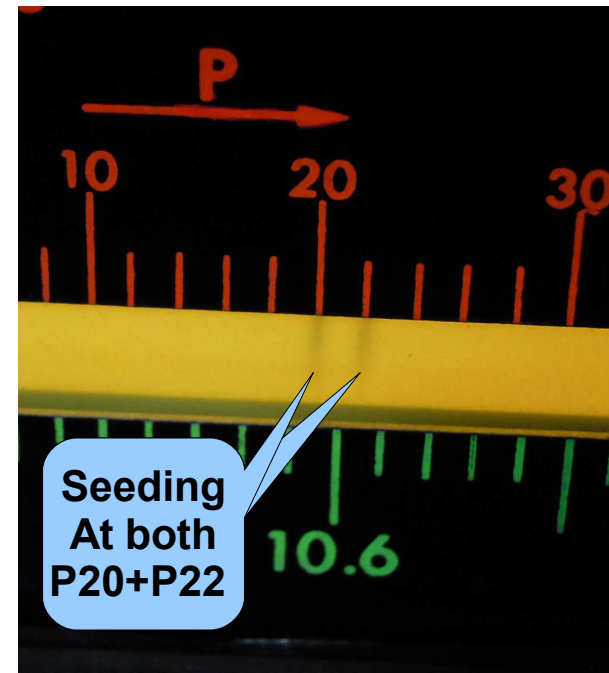
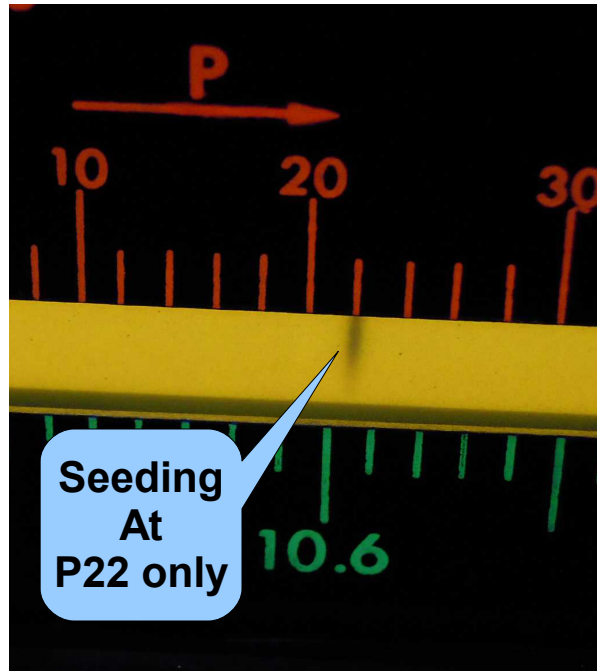
(Far-field beam
profile shown
below)



Typical long-term beam pointing stability
(open-loop, free-run)

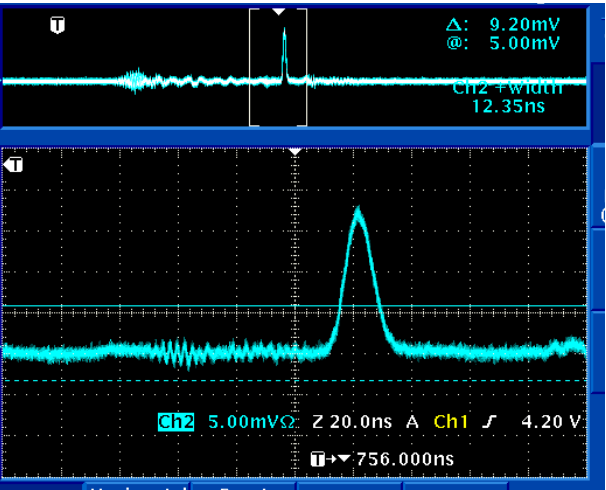


Performance of multi-line Master Oscillator – experimental confirmation of multi-line output (early 2011)

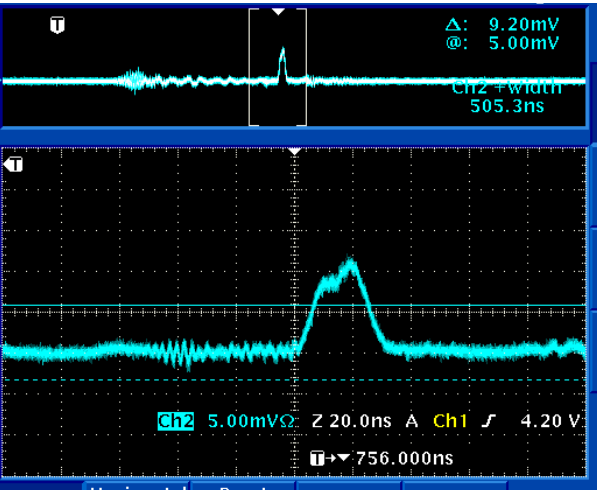


Demonstration of electronic spectrum control by switching individual seeders on and off – operation at P20+P22 lines

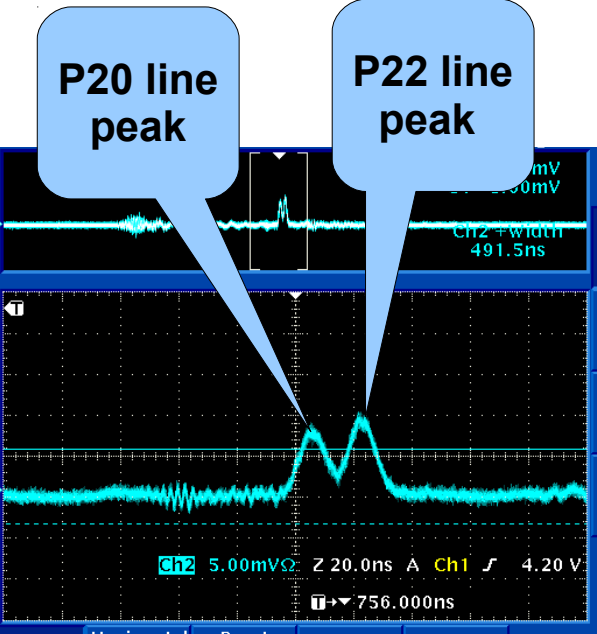
Performance of multi-line Master Oscillator – pulsewidth tunability demonstration (early 2011)



0ns relative offset
13ns FWHM
10.5W output



10ns relative offset
20ns FWHM
10.5W output



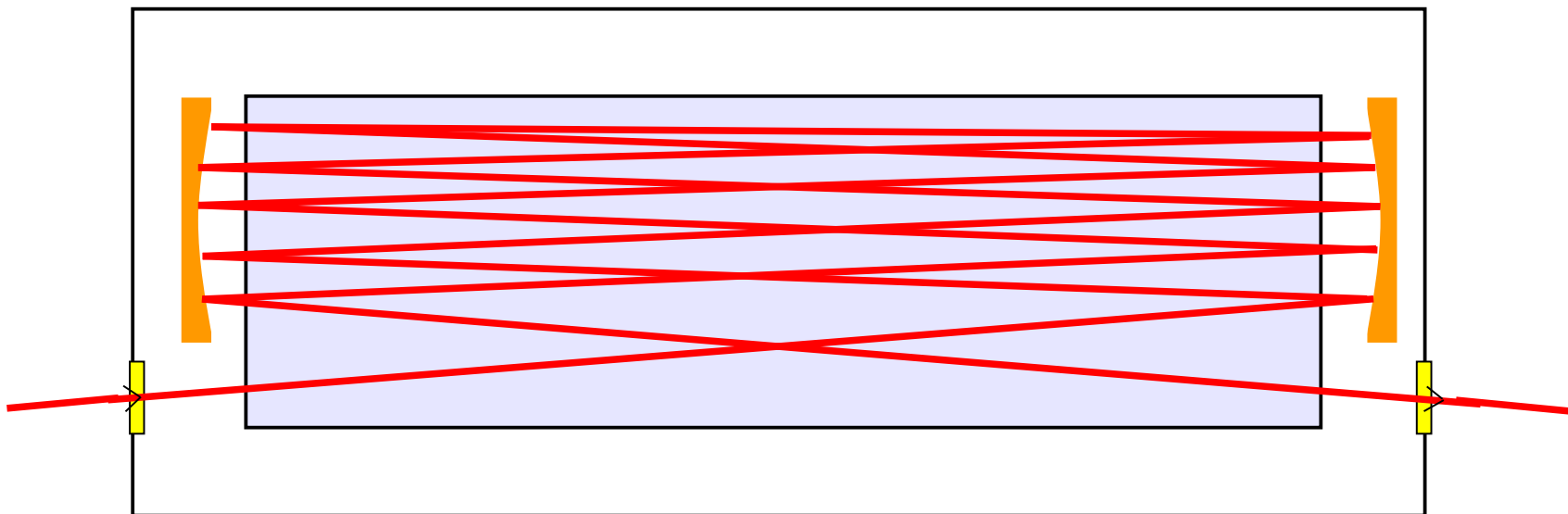
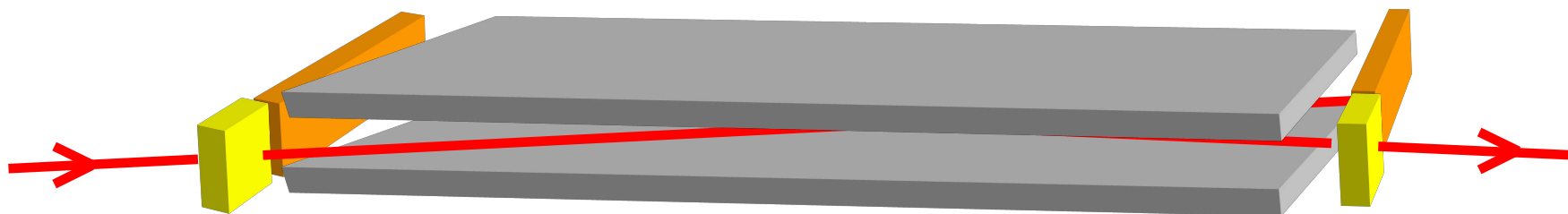
15ns relative offset
25ns FWHM
10.5W output

Demonstration of electronic pulse-width control by relative time offset of seeding pulses – operation at P20+P22 lines

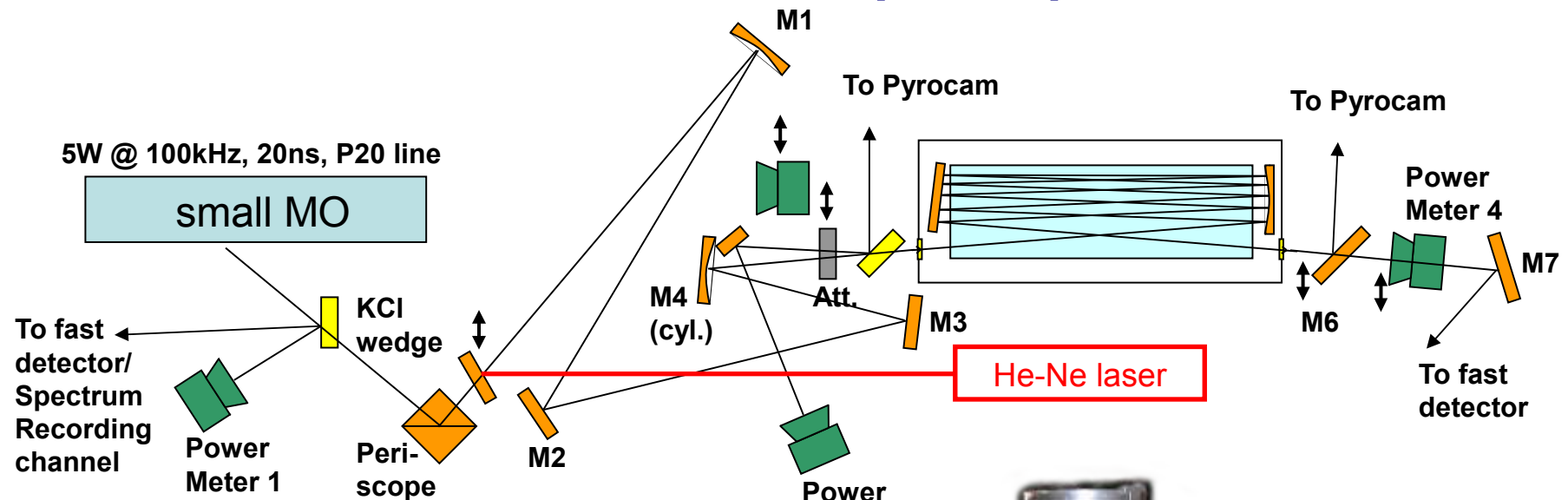
Efficient pre-amplification up to Multi-kW power level

- **Slab-waveguide amplifiers - concept**
- **Small-scale slab amplifier development**
- **Large-scale slab amplifier development**
- **Recent experimental results**

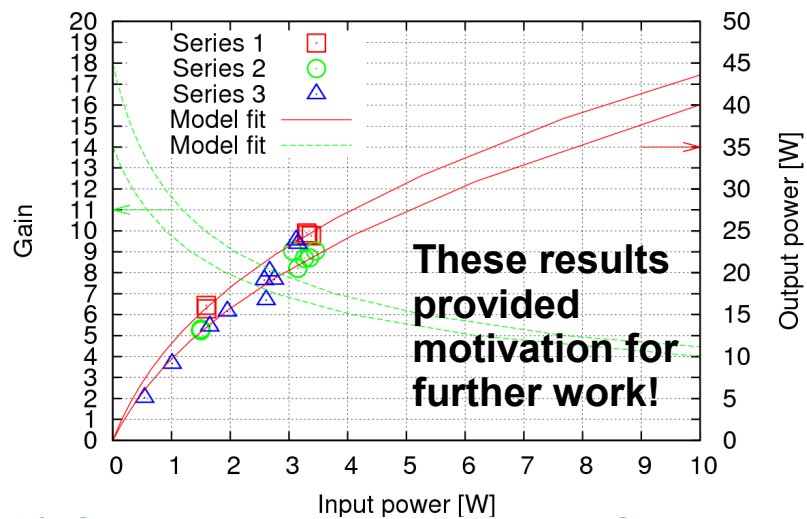
Slab-waveguide amplifier based on RF-discharge-excited diffusion-cooled CO₂ lasers - concept



First experiments in ILP in St. Petersburg with small-scale slab amplifier* (2007)



9-pass amplifier characteristics - P20 line

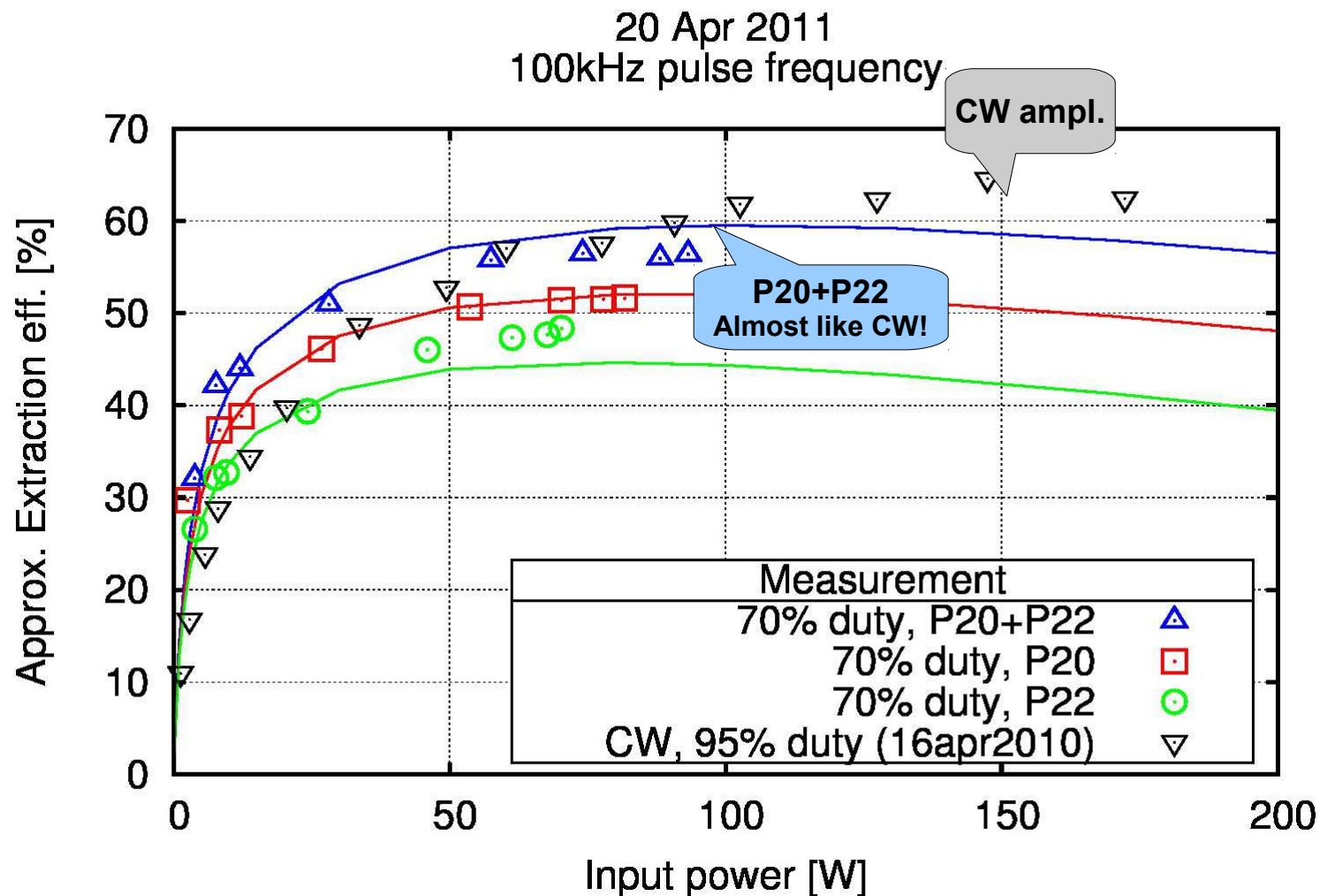


These results provided motivation for further work!

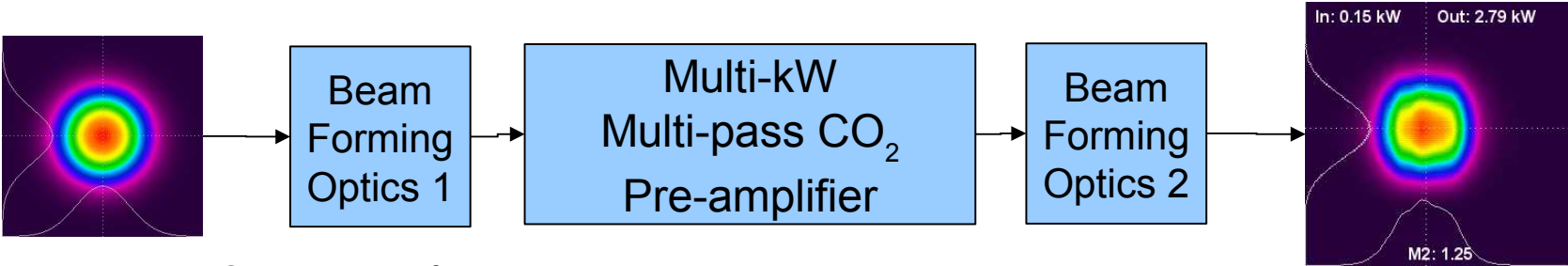


* Invited paper:
 V. Sherstobitov, A. Rodionov, D. Goryachkin
 N. Romanov, A. Endo, K. Nowak,
 Multipass slab CO₂ amplifiers for application in EUV lithography,
 EUVL Litho Workshop, 10-12 June 2008, Maui, Hawaii, US

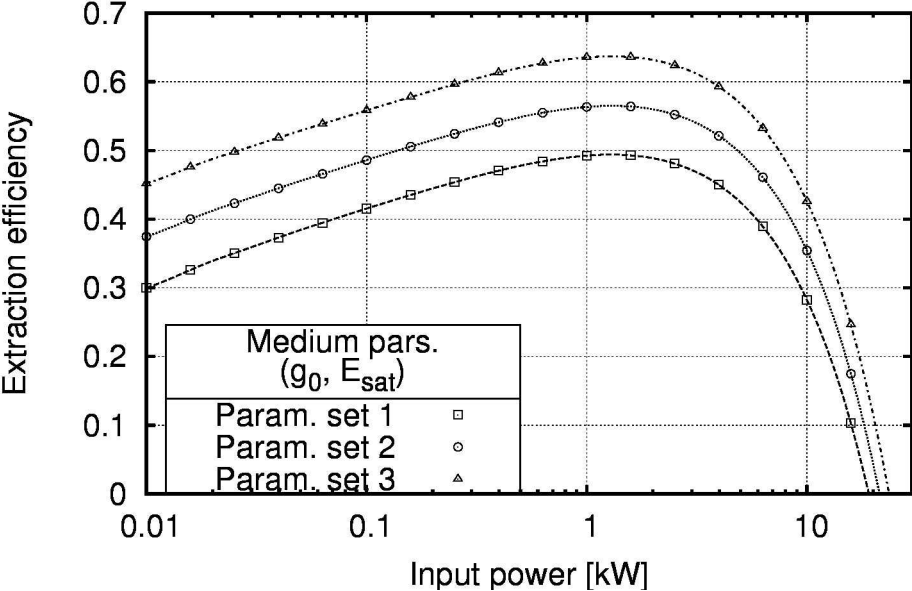
Small-scale slab-amplifier – recent developments (2008-2011) – achieved near-CW efficiency at multi-line operation



Multi-pass slab-waveguide based short pulse amplifier performance – model prediction (2009)



Calculated performance of multi-pass pre-amplifier

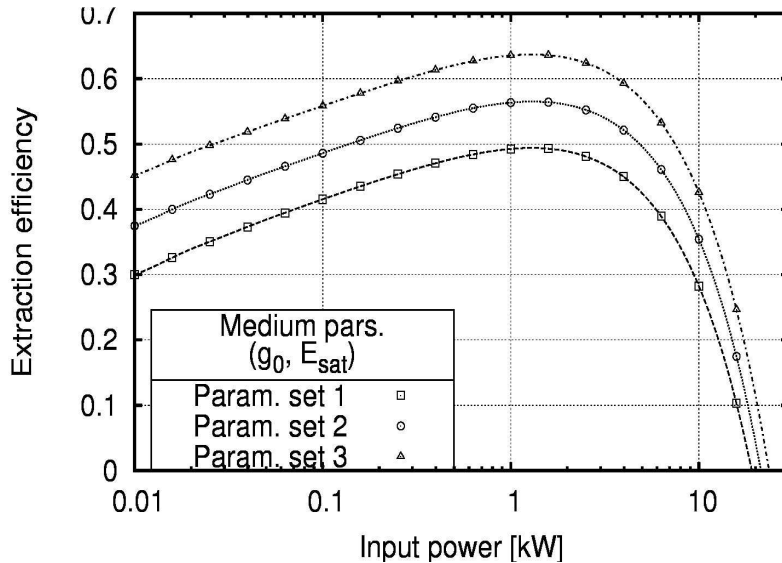


- Good beam quality $M^2 < 2$ at multi-kW level predicted
- Compact size
- Extr. Efficiency better than 40%

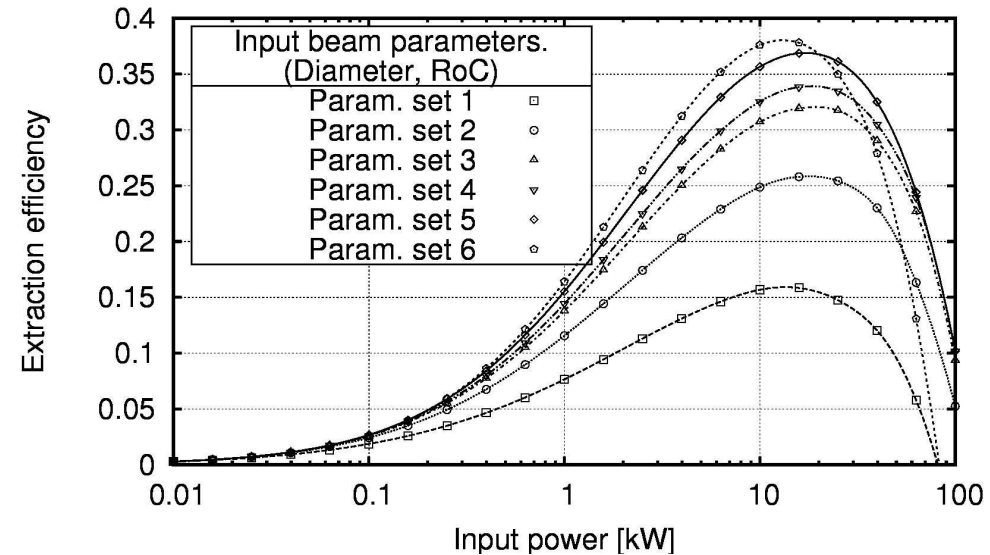
Multi-pass slab vs single-pass FAF amplifier – illustration of efficient pre-amplification

Single line operation P20 at 100kHz repetition, 20 ns

Prediction of pulsed performance of large-scale slab amplifier, 20ns, 100kHz



Simulated performance of FAF amplifier based on experimentally determined medium parameters, 20ns, 100kHz



Large-scale multi-pass slab amplifier

Max. Extr. Efficiency*: 35-60%
Max. extracted power: ~4kW
Input for max Extr. Eff.: 1-3kW
Power consumption: ~70kW

20kW FAF amplifier

Max. Extr. Efficiency*: 35%
Max. extracted power: ~7kW
Input for max Extr. Eff.: 10-30kW
Power consumption: ~160kW

* As compared to CW power output at full RF duty

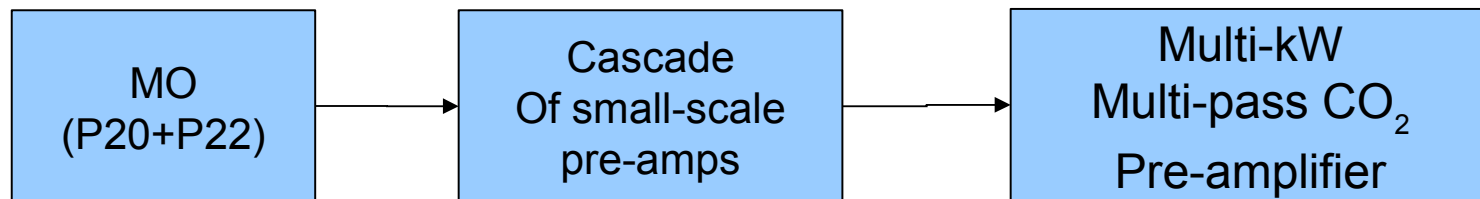
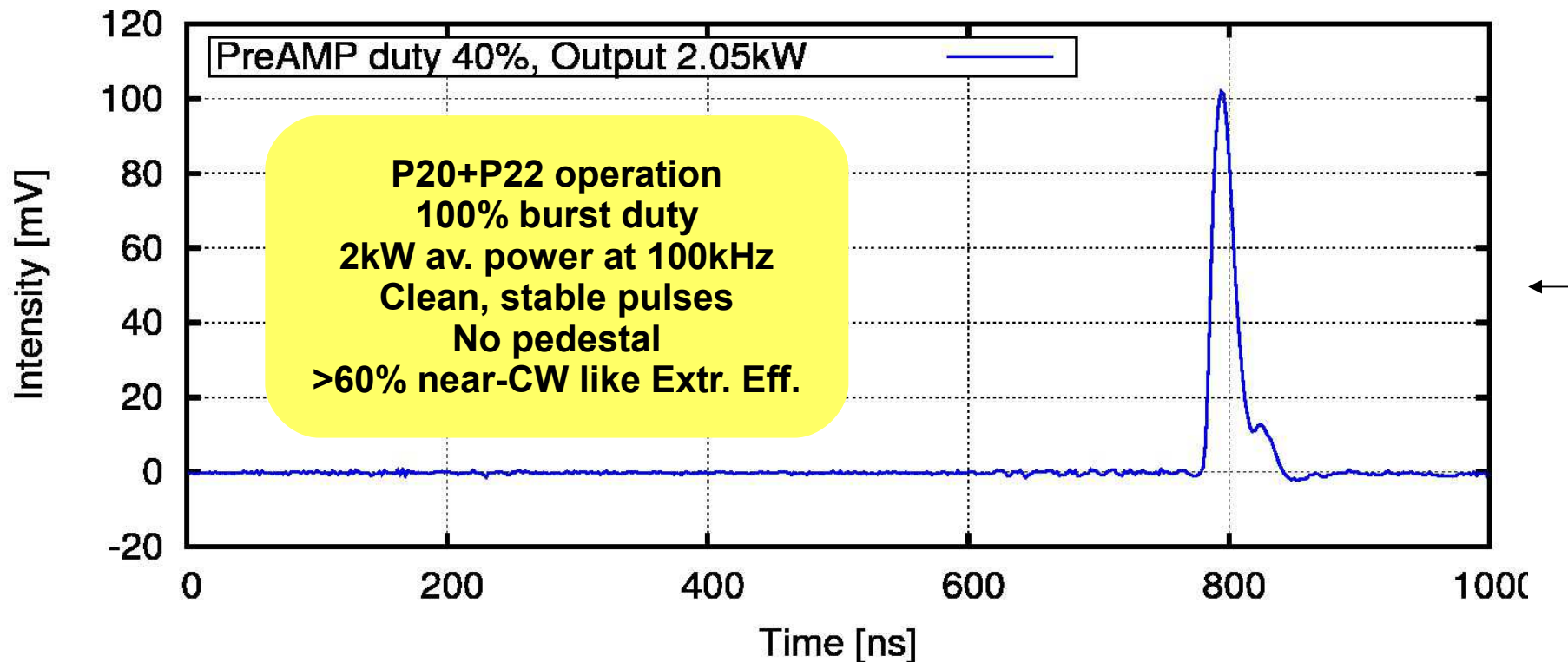


Multi-kW multi-line pulsed output achieved to date

- **Recent multi-line amplification results using prototype laser system**
 - Multi-line Master Oscillator
 - Small-scale amplifier cascade
 - Large-scale slab amplifier

Recent multi-line amplification results - 2kW achieved at near-CW extraction (August 2011)

Output pulse shape (8 Aug 2011)



Summary

- **A multi-line oscillator was designed and developed (10-20W output)**
 - ✓ **Multi-line (currently P20+P22, more planned soon)**
 - ✓ **High stability high quality output beam**
 - ✓ **Pulse-width tunable**
 - ✓ **Resistant to back-seeding by ASE**
- **A system of small-scale slab amplifiers was designed, developed and tested**
 - ✓ **boost from 10W input to 200W output**
 - ✓ **50-60% extraction efficiency recorded**
- **A large-scale slab amplifier was designed, developed and tested**
 - ✓ **Boost from 150-200W level to multi-kW level**
 - ✓ **>2kW output power achieved from 160-180W input (Aug 2011)**
 - ✓ **High extraction efficiency >60% confirmed at 2 line operation (P20+P22)**
 - **>60% extraction at >20% RF duty recorded**

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